



Docket No.: 042390.P11362

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Brian S. Doyle, et al.

Application No.: 09/895,579

Filed: June 29, 2001

For: CREATION OF HIGH MOBILITY  
CHANNELS IN THIN-BODY SOI  
DEVICES

Examiner: David Nhu

Art Group: 2818

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**RESPONSE TO RESTRICTION REQUIREMENT**

Assistant Commissioner for Patents  
Washington, DC 20231-9998

Sir:

In the Office Action mailed March 4, 2002, the Examiner contends that Applicants claim two distinct inventions; namely, a method of making a wafer and such a wafer. Thus, pursuant to 35 U.S.C. 121, the Examiner requires Applicants to restrict the application to one of the alleged two inventions.

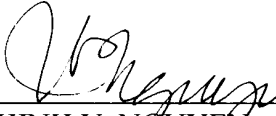
In compliance with 35 U.S.C. §121, Applicants elect the second set (Claims 14-19) related to a wafer.

In view of the foregoing, it is respectfully submitted that the current pending claims are in condition for allowance and such action is respectfully solicited.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Dated: April 4, 2002

  
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**CERTIFICATE OF MAILING**

*I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231 on: April 4, 2002.*

  
Barbara Hayashi